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## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants:

Y. KURATA, et al.

Application No.:

10/049,672

Filed:

February 15, 2002

For:

POLISHING MEDIUM FOR CHEMICAL-MECHANICAL

POLISHING, AND METHOD OF POLISHING

Examiner:

1765

Group:

D. Deo

## <u>AMENDMENT</u>

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

July 8, 2004

Sir:

In response to the Office Action mailed January 8, 2004, please amend the above-identified application as listed in the following, and as set forth on the following pages:

Amendments to the Claims; and

Remarks are included following the amendments.